

IR340LM..CS05CB SERIES

Rectangular 350 x 230 mils Junction Size:

■ Wafer Size:

1000 to 1200 V ■ V_{RRM} Class:

Glassivated MOAT Passivation Process:

■ Reference IR Packaged Part: 60EPF Series

Major Ratings and Characteristics

Р	Parameters		Units	Test Conditions	
V	r FM	Maximum Forward Voltage	1300 mV	$T_J = 25^{\circ}C, I_F = 60 A$	
V	RRM	Reverse Breakdown Voltage Range	1000 to 1200 V	T _J =25°C, I _{RRM} =100 μA	(1)

⁽¹⁾ Nitrogen flow on die edge.

Mechanical Characteristics

Nominal Back Metal Composition, Thickness	Cr - Ni - Ag (1 KA - 4 KA - 6 KA)		
Nominal Front Metal Composition, Thickness	100% AI, (20 μm)		
Chip Dimensions	350 x 230 mils (8.89x5.84 mm) - see drawing		
WaferDiameter	100 mm, with std. < 110 > flat		
WaferThickness	260 µm		
Maximum Width of Sawing Line	45 µm		
Reject Ink Dot Size	0.25 mm diameter minimum		
Ink Dot Location	See drawing		
Recommended Storage Environment	Storage in original container, in dessicated nitrogen, with no contamination		
www.irf.com	See drawing Storage in original container, in dessicated nitrogen, with no contamination		

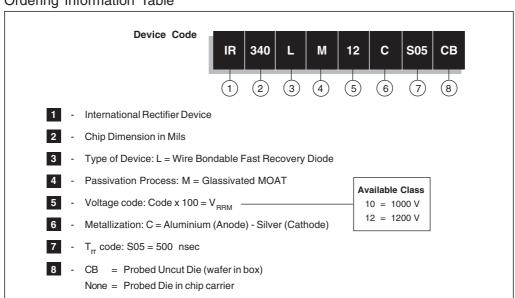
IR340LM..CS05CB Series

Bulletin I0114J 05/00

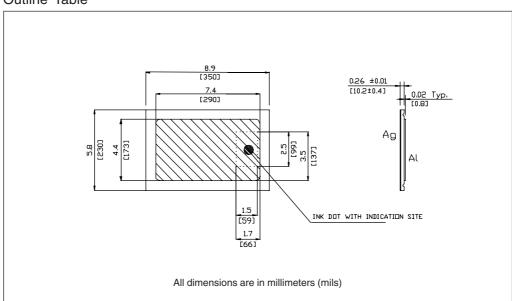
International

TOR Rectifier

Ordering Information Table



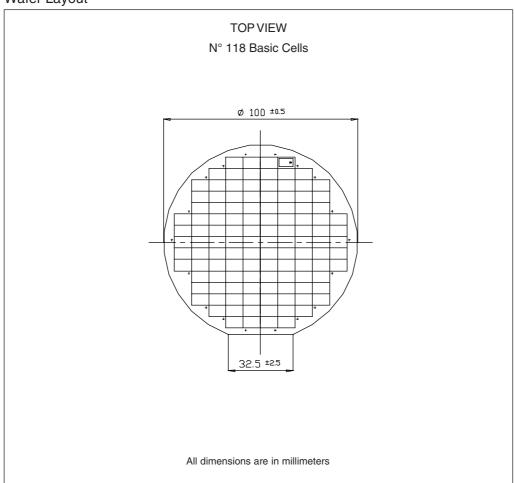
Outline Table



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Wafer Layout



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